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(71) Applicant (for all designated States except US): **SOLVAY (SOCIETE ANONYME)** [BE/BE]; Département de la Propriété Intellectuelle, Rue du Prince Albert 33, B-1050 Brussels (BE).

(72) Inventor; and

(75) Inventor/Applicant (for US only): **RENIERS, François** [BE/BE]; Faculty of Sciences -, Analytical and interfacial Chemistry, Université Libre de Bruxelles, Boulevard du Triomphe 2, B-1050 Brussels (BE).

(74) Agents: **JACQUES, Philippe** et al.; Solvay (Société Anonyme), Rue de Ransbeek 310, B-1120 Bruxelles (BE).

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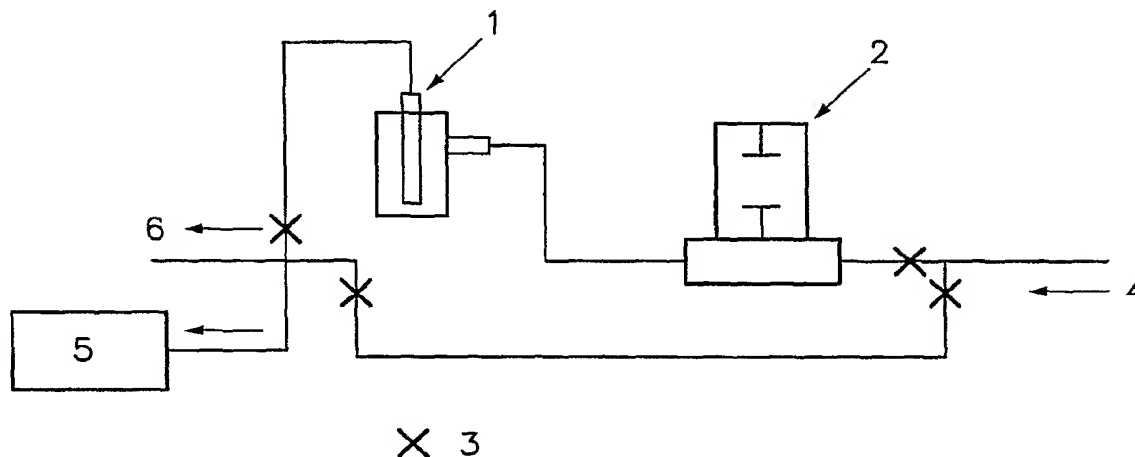
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[Continued on next page]

(54) Title: METHOD OF FORMING A PLASMA AND USE FOR DECONTAMINATION BY DECOMPOSITION OF TOXIC SUBSTANCES



(57) Abstract: Method of forming a plasma intended for the chemical treatment of substances, in which at least two electrodes and a layer of dielectric material located between the two electrodes are placed in a chamber in order to form plasma glow discharges, in which a controlled flow comprising oxygen is introduced into the chamber, the controlled flow of gas during its introduction into the chamber containing none of the substances to be treated.

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ZM, ZW, ARIPO patent (BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW), Eurasian patent (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European patent (AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IS, IT, LT, LU, MC, NL, PL, PT, RO, SE, SI, SK, TR), OAPI patent (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG)

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